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3M-NANO is the annual International Conference on Manipulation, Manufacturing and Measurement on the Nanoscale; it will be held in August in Changchun, China. The ultimate ambition of this conference series is to bridge the gap between nanosciences and engineering sciences, aiming at technology opportunities and new markets. The advanced technologies for manipulation, manufacturing and measurement at nanoscale promise novel revolutionary products and methods in numerous areas of application. Scientists working in research fields related to 3M-NANO topics are invited to submit papers. All accepted full papers (presented at the conference and following IEEE format) will be submitted in IEEE Xplore database and Ei Compendex. Selected papers will be recommended for publication in the IEEE Trans. on Automation Science & Engineering, Int. J of Nanomanufacturing, IFAC Mechatronics, Int. J of Optomechatronics, J of Micro-Bio Robotics, Journal of Bionic Engineering, Light (Science & Applications), Optics and Precision Engineering, International Journal of Extreme Manufacturing and Material Today Bio and other SCI/EI journals.

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Venue: Changchun, is the capital of Jilin Province. In the eyes of a Chinese, it is a Chinese version of a combination of Detroit and Hollywood. It has China's largest motor vehicle plant and its biggest film studio. Lying in Songliao Plain hinterland, Changchun's terrain is plain and open. Its urban area is 250~350 meters above sea level. It belongs to the continental monsoon climate with a clear difference in the four seasons. Spring is dry and windy; summer is damp and hot with much rainfall; autumn is clean and clear and winter is cold and long. However, Changchun's climate is generally temperate and pleasant and it has enjoyed the reputation of "Spring City of North of the Great Wall".

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